ELECTRON DIFFRACTION STUDY OF CuGaS2 FILM

Abstract

In present work, the results of electron diffraction investigations of structures of amorphous thin films of $CuGaS_2$ have been given and function of radial distribution of atoms (FRDA) has been calculated. Appropriate coordination number n=4,1 we obtained from calculating the area under the first peak, also indicates tetrahedral surrounded by atoms of copper and gallium. During the deposition of this ternary compound on a substrate with T=423-433 K the mixture of polycrystalline single crystal is formed. With the increase of temprature the intensivity of polycrystallines decreases and point reflections according to the monocrystal increases. Further increase of the substrate temperature to 453 K LiF leads to the formation of a perfect single crystal.

Superstructure phase $CuGaS_2$ is oriented on (100) plane parallel to the faces LiF. During epitaxial growth on LiF $CuGaS_2$ one unit cell superstructure is mated with four cells of the substrate. Between periods of lattices of the initial phase and superstructure there are simple relations common with: $a \approx 3a_0$; $c \approx 2c_0$.

Keywords. Diffraction, phase, atoms, structure, superstructure, amorphous, compositions

1.Introduction.

A number of works [1-3] were devoted to X- ray studies of crystalline structures of the compounds of group A^1 - B^3 - C^6 . However in none of the known works

27	patterns of short range order structure of amorphous compositions CuGaS ₂ were
28	determined.
29	The reason for this can be found either by difficulties in establishing
30	conditions for amorphous films of these compounds, or trends in amorphous films to $$ the
31	more dense packing.
32	Amorphous thin films CuGaS ₂ of thickness 25 nm were obtained by evaporation
33	alloys CuGaS ₂ in the vacuum of 10^{-4} PA on the substrate NaCl, KCl
34	and LiF located at room temperature. NaCl, KCl and LiF ion crystals have been
35	choosen as substarte because by solving these crystals in the water $thin\ CuGaS_2$
36	layers formed on them seperating stay on the surface of water and which is kept in the
37	metal net with diameter of 0.1-0.3 mm.
38	On the other hand these subtrates with cubic structure of different elementary cell
39	parameters affect epitoxially on crystallisation in primary formation of condensate and
	parameters affect epitoxially on crystallisation in primary formation of condensate and further thermo-processing.
39	
39 40	further thermo-processing.
39 40 41	further thermo-processing. The rate of deposition of films for all cases was the 1 1.5 nm/sec.
39 40 41 42	further thermo-processing. The rate of deposition of films for all cases was the 11.5nm/sec . Amorphous phase CuGaS ₂ is formed until T_s =383 K, crystallization, which can
39 40 41 42 43	further thermo-processing. The rate of deposition of films for all cases was the 11.5nm/sec . Amorphous phase CuGaS2 is formed until $T_s = 383 \text{K}$, crystallization, which can lead to the formation of polycrystalline with periods of a tetragonal lattice,
39 40 41 42 43 44	further thermo-processing. The rate of deposition of films for all cases was the 11.5nm/sec . Amorphous phase CuGaS2 is formed until $T_s=383 \text{K}$, crystallization, which can lead to the formation of polycrystalline with periods of a tetragonal lattice, military data [5].
39 40 41 42 43 44	further thermo-processing. The rate of deposition of films for all cases was the 1 1.5 nm/sec. Amorphous phase CuGaS ₂ is formed until T_s =383 K, crystallization, which can lead to the formation of polycrystalline with periods of a tetragonal lattice, military data [5]. Amorphous films formed with values S =4 π sin θ/λ =24.10; 29.50; 53.70; 83,70 nm
39 40 41 42 43 44 45 46	further thermo-processing. The rate of deposition of films for all cases was the 1 1.5 nm/sec. Amorphous phase CuGaS2 is formed until $T_s=383~K$, crystallization, which can lead to the formation of polycrystalline with periods of a tetragonal lattice, military data [5]. Amorphous films formed with values $S=4\pi\sin\theta/\lambda=24.10$; 29.50; 53.70; 83,70 nm ⁻¹ (Fig.1) after heat treatment at $T_s=380~K$ are crystallized in the structure of chalcopyrite
39 40 41 42 43 44 45 46	further thermo-processing. The rate of deposition of films for all cases was the 1 1.5 nm/sec. Amorphous phase CuGaS2 is formed until T_s =383 K, crystallization, which can lead to the formation of polycrystalline with periods of a tetragonal lattice, military data [5]. Amorphous films formed with values S=4 π sin0/ λ =24.10; 29.50; 53.70; 83,70 nm ⁻¹ (Fig.1)after heat treatment at T_s =380 K are crystallized in the structure of chalcopyrite tetragonal lattice CuGaS2 with periods a=0,535; c=1.047 nm, CBC I $\overline{4}$ 2d [5].

Comment [u1]: This is present work film preparation or standard preparation from previous work? Need reference here!!

numbers (CN) may be determined by the functions of atom radial distribution (FARD) 51 52 prepared according to the retraining Fourier intensity of the coherent scattering of electrons. 53 $4\pi r^2 \sum_{m} K_{mPm} (r) = 4\pi r^2 U_0 \sum_{m} K_m +$ 54 $\frac{2r}{\pi} \sum_{m} K_{m} \int_{0}^{\infty} St(s) sin(Sr) dS \qquad (1)[12],$ 55 Here $U_0 = d/Mm_h$ - average density of atoms, d-amorph object density, M -molecular 56 mass, m_H =1.65x10⁻²⁴ gr- hydrogen atom mass $\rho_m(r)$ - function of atom density. S = 57 $4\pi^{\sin\theta/\lambda}$ is the half of scattering angle, $K_m^2 = (Z_m/Z_l)(8)$ – scattering capability of 58 atoms and Zm - the order number of the atom included in the content of expression,: Z₁-59 the order number of lighter atom of the expression in the periodical system. 60 $I(S) = (\frac{I_h^k(S)}{\sum_{f \in S}}(S) - 1) \sum_m \text{ Km } (9) - \text{interferention function }.$ 61 Reliable, (FARD) can only be obtained when integrating from 0 to ∞ or before S_2 , if 62 functions do not feel out of oscillate that occurs in strongly disordered 63 interference 64 systems. The intensity of scattering can be determined experimentally with sufficient accuracy only on some interval of values $S=4\pi\sin\theta/\lambda$, so practically the integration in 65 (1) is over a finite interval from S_1 to S_2 . 66 67

Comment [u2]: Please provide preparation of amorphous film CuGaS₂ in this section. Author only mentioned the characterization and parameter and simple explanation only require.

3. Results and discussion

69 Intensity curve electron scattering from amorphous films CuGaS₂ were obtained

on electronography brand EMR-102 in the form of graphs of dependences

of the intensity of scattering angles, i.e. from S= $4\pi\sin\theta/\lambda$ (Fig.1).

72 Function i(S)

68

70 71

73 graphically depicted in (Figure 2.), were used to calculate (FARD) for CuGaS₂ (fig. 3.)

Comment [u3]: Fig. 2 instead of Figure 2.

Comment [u4]: Fig. 3 instead of fig. 3.

- 74 according to formula (1). The calculation was carried out on the programmer "RADIADIS
- 75 "on the computer IBM. Intervals of variables accounted for $\Delta r = 0.01$ nm⁻¹,
- 76 $\Delta S = 0.01 \text{ nm}^{-1}$.
- 77 (FARD) CuGaS₂ (fig. 3.) contains four asymmetric highs one of which is isolated and a
- 78 group of false highs, emanating from the larger values of S.
- The area under the respective highs, manifesting themselves in $r_1 = 0.234$; $r_2 = 0.244$;
- 80 $r_3 = 0.282$; $r_4 = 0.411$ nm. are equal $\Delta_1 = 16.0$; $\Delta_2 = 20.3$; $\Delta_3 = 55.5$ and $\Delta_4 = 80.0$
- 81 nm respectively.
- Distance $r_1 = 0.234$ nm revealed on (FARD) CuGaS₂, is the distance between
- atoms Cu-S, as tetrahedral covalent radii are equal to $r_{Cu} = 0.135$ and $r_S = 0.104$
- 84 nm. Appropriate coordination number n = 4,1 obtained from calculating the area
- 85 under the first peak, also indicates tetrahedral surrounded by atoms of copper
- and gallium.
- Radius of the second coordination sphere equal to $r_2 = 0.244$ nm which could be
- 88 able to interpret as the distance Ga-S. The ionic radii of gallium and sulfur atoms
- 89 constitute $r_{Ga} = 0.127$ and $r_S = 0.104$ nm, for which coordination number is six.
- Meaning coordination number equal to $n_2 = 6.3$ received by us from calculating
- 91 the area of the second peak on (FARD) CuGaS₂ also indicates the octahedral environment
- 92 of gallium atoms by sulfur atoms.
- The bond length between the atoms equal to $r_3 = 0.282$ nm corresponds to the
- 94 distance between the same atoms Ga-Ga. Fourth maximum detected at a distance
- nm can be referred to the distance between the negatively charged divalent atoms (S^{2-}).

Comment [u5]: Fig. 3.

96	It should be noted that on (FARD) CuGaS $_2$ arise false details too, and they its
97	may arise due to errors in the experimental intensity curve or cliff: they are mainly
98	manifested in the large values of S and belong to groups with slightly blurred large
99	coordination number equal to 8, 10 and 12.
100	During the deposition of this ternary compound on the substrate with $T_s = 423$ -
101	433 K a mixture of polycrystalline with single crystal is formed (Fig. 4.).
102	On the electronogramms from the shown mixture apear more additional weaker
103	reflexes. As a result of increase in temperature
104	intensity polycrystalline lines are reduced but the intensity of
105	point reflections corresponding to single crystal grow.
106	Further increase of the substrate temperature to 453 K LiF leads to the formation of
107	a perfect single crystal. On electron diffraction from single crystals
108	(Fig. 5), discontinued at right angles strong point reflexes, forming a square grid
109	displayed on the basis of hk0 reflexes known lattice CuGaS ₂ . Indexing of all
110	reflexes, including additional low in intensity lines is achieved with parameter
111	a = 1.605 nm.
112	Period "c", established by electron diffraction, shot at an angle $\phi = 35^{\circ}$ was found to be
113	2.102 nm.
114	Between periods of lattices of the initial phase and superstructure there
115	are simple relations common with: $a \approx 3a_0; c \approx 2c_0.$ In the electron derived from film
116	on substrates formulated with higher temperatures ($T_s = 473 \text{ K}$), dynamic effects
117	appear (Figure 6.). The microstructure of single

crystal layers $CuGaS_2$ from which there is a dynamic high energy electron scattering is

shown in Fig. 7 (X 20000). Thus, substrates can be LiF CuGaS $_{\!2}$ samples with varying subst

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Comment [u6]: Fig. 3

120	ructure including a super lattice phase super period. Growth mechanism of single-crystal				
121	thin - film and nano scaleepitaxial films is a model for many heterogeneous and				
122	topochemical processes.				
123	However, the existing theory of crystallization cannot explain all of the results of a large a				
124	mount of experimental work -				
125	there is a clear discrepancy between the flow: The totality of new facts and their level of				
126	theoretical understanding of the experimentally observed facts with a unified position				
127	cannot be considered. In existing theories of crystallization there is still no consensus or				
128	what is the main factor in orienting epitaxial.				
129	Generally accepted explanation is not considered as such a statement and that the main				
130	factor in orienting epitaxial is a single-crystal structure -				
131	substrates. Focused on the growth of amorphous boundary layers prepared on the surface				
132	of the substrate crystals [6,7], is proof that the basic structure of crystals does not				
133	determine substrate orientation effects.				
134	Oriented crystallization on the outside boundary of polycrystalline layers [8-				
135	9], as well as the growth of not only epitaxial films, but also highly perfect single				
136	crystals through the amorphous boundary				
137	layers [10] makes relate to the theory of crystallization based on the structure of single-				
138	crystal substrates seeds very carefully. Since many experimental				
139	works performed revealed a clear discrepancy between the facts and their level				
140	of theoretical understanding, it is not yet possible to formulate some general criteria for the				
141	formation of epitaxial films and single crystal. Therefore, conditions for the				
142	formation of single-crystal films to day, as shown in the previous chapter, are				
143	established only experimentally.				

144	Since the	bulk crystal	lattice C	CuGaS ₂	is	ordered,	in order to	<mark>explain</mark>	the
145	formation of su	<mark>uper lattice phase</mark>	e we	should as	ssume th	at it is	the disord	ered ph	ase.
146	Disordering or	dered - structure	es	some	e	of		the in	itial
147	of the atoms in	it are defective,	resulting	superstruc	cture sho	uld have	a statistical	averag	e
148	frequency. Re	gularities of simi	ilar phase	transition	s were fi	rst establ	ished for th	e phase	s of
149	the chemical g	roup of compour	$ds A^3B^3$	$C_{2}^{6}[4].$					
150	Superstructure	e phase CuGaS ₂ is	s						
151	oriented (100)	plane parallel to	the faces	[11] LiF. I	Ouring e	pitaxial g	rowth on L	iF CuG	aS_2
152	one unit cell						(UC) super	structu	re is
153	mated with fou	ar cells of the sub	strate. Re	lative disc	repancy	mating c	rystal lattic	es in	this
154	case is 2,9%.								
155	4. Conclusion	S.							
156	In CuGaS ₂ an	norph layers sh	ort range	e order pa	<mark>ramete</mark>	<mark>rs have</mark> l	<mark>oeen studie</mark>	ed and	it is
157	shown that	$\frac{distance}{distance} r_1 = 0$	0,234 nm	revealed o	on (FAF	D) CuG	aS2, is th	<mark>e dista</mark>	nce
158	<mark>between ato</mark>	oms Cu-S, as tetr	rahedral	<mark>covalent</mark> r	adii are	equal	$r_{Cu} = 0.12$	35 ar	nd
159	$r_{\rm S} = 0.104 \rm nm$	ı. Appropriat	e co	ordinatio	n nui	nber n	n = 4,1	obtair	ned
160	from calculat	ing the are	ea 1	under the	first pe	ak,	also	indica	ites
161	tetrahedral s	urrounded by	a	atoms of		copper	ar	<mark>nd galli</mark>	<mark>um.</mark>
162	Radius of the	second coordina	ation sph	iere equal	to $r_2 =$	0,244 n	m which	could	be
163	able to interp	ret as the distan	ice Ga-S.	The ionic	c radii	<mark>of galliu</mark>	m and sul	fur ato	oms
164	constitute r	$_{Ga} = 0,127$ and	$r_S = 0.10$	⁴ nm, for	which	coordi	ination nur	nber is	six.
165	Meaning cod	ordination num	ber equa	$\frac{1}{1}$ to $\frac{n_2}{n_2}$	= 6,3 re	eceived b	y us from o	calcula	ting

tne area of the second peak on (FARD) CuGaS2 also indicates the octanedral
environment of gallium atoms by sulfur atoms. It is shown that thin films on
different substartes cryistalize after thermal processing.
During the deposition of this ternary compound on the substrate with $Ts = 423$ -
433 K a mixture of polycrystalline with single crystal is formed.
Further increase of the substrate temperature to $453KLiF$ leads to the formation of
a perfect single crystal.
Superstructure phase CuGaS2 is oriented (100) plane parallel to the faces [11] LiF.
During epitaxial growth on LiF CuGaS2 one unit cell (UC) superstructure is
mated with four cells of the substrate. Relative discrepancy mating crystal
lattices in this case is 2,9%.
It is found that between periods of lattices of the initial phase and superstructure
there are simple relations common with: $a \approx 3a0$; $c \approx 2c0$.
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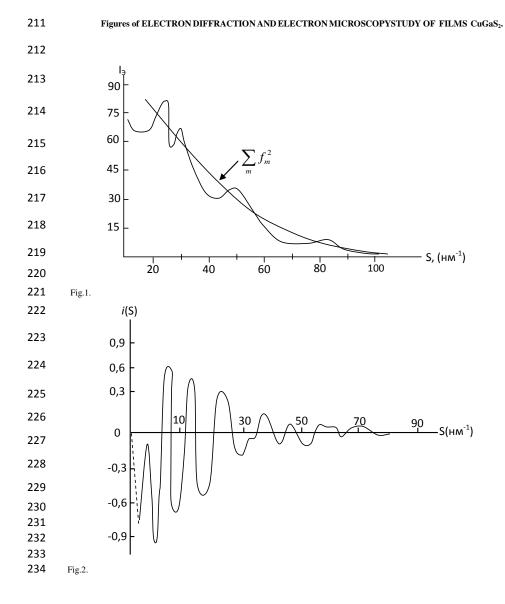
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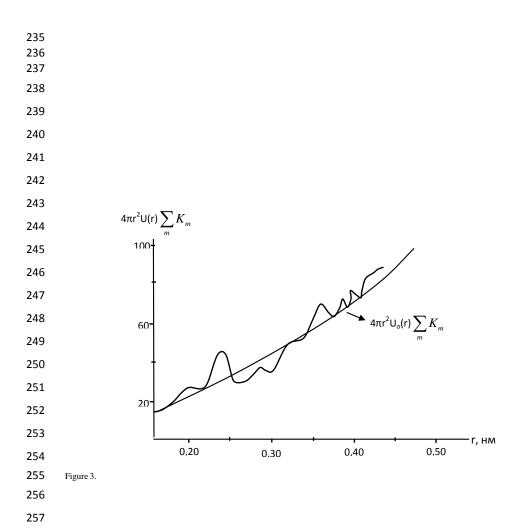
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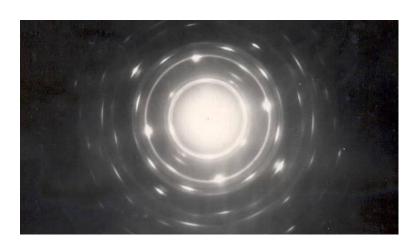
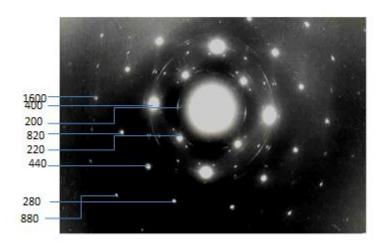
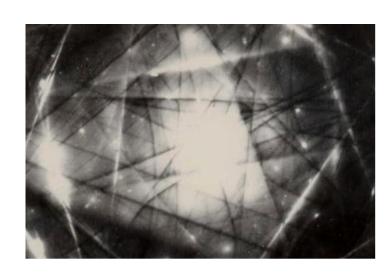


Fig. 4.

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285286 Fig.6.

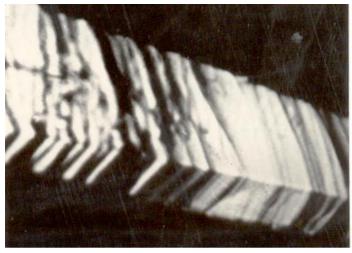


Fig. 7.

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293	Captions to figures of ELECTRON DIFFRACTION AND ELECTRON
294	MICROSCOPYSTUDY OF FILMS CuGaS ₂ .
295	
296	Fig. 1. The intensity curves of amorphous CuGaS ₂ .
297	
298	Fig.2. Interference scattering function of electrons of amorphous CuGaS ₂
299	
300	Fig. 3. The curve of radial distribution of atoms of CuGaS ₂
301	
302	Fig. 4. Electron diffraction single crystal mixture with polycrystalline CuGaS_2
303	
304	Fig. 5. Electron diffraction from single crystal super lattic phase CuGaS ₂
305	
306	Fig. 6. Electron diffraction pattern with Kikuchi lines from
307	
308	single crystal CuGaS ₂ high perfections.
309	
310	Fig. 7. The microstructure of single-crystal beds of $\text{CuGaS}_2(\text{H}20000)$.
211	